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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/994,146	11/26/2001	Min-Su Kim	SAM-0274	8596
7590 11/28/2003			EXAMINER	
Steven M. Mills			HU, SHOUXIANG	
MILLS & ON	ELLO LLP		ADTIBUT	D 4 DCD 1811 (DCD
Suite 605			ART UNIT	PAPER NUMBER
Eleven Beacon	n Street		2811	
Boston, MA	02108		DATE MAILED: 11/28/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)					
:	09/994,146	KIM ET AL.					
Office Action Summary	Examiner	Art Unit					
	Shouxiang Hu	2811 A-4	\int				
The MAILING DATE of this communication ap		correspondence address					
Period for Reply	VIO OFT TO EVOIDE AMOUTH	(C) FROM					
A SHORTENED STATUTORY PERIOD FOR REPL THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1. after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a rep If NO period for reply is specified above, the maximum statutory period - Failure to reply within the set or extended period for reply will, by statut - Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b). Status	136(a). In no event, however, may a reply be tired by within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from the cause the application to become ABANDONE	nety filed s will be considered timety. I the mailing date of this communication. D (35 U.S.C. § 133).					
1) Responsive to communication(s) filed on 09 S	September 2003.						
2a)⊠ This action is FINAL . 2b)☐ This	s action is non-final.						
3) Since this application is in condition for allowance except for formal matters, prosecution as to the ments is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
Disposition of Claims							
4)⊠ Claim(s) <u>18-36</u> is/are pending in the application.							
	4a) Of the above claim(s) is/are withdrawn from consideration.						
	5) Claim(s) is/are allowed.						
	6) Claim(s) 18-36 is/are rejected.						
, ==	7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or election requirement.						
Application Papers	,						
9)⊠ The specification is objected to by the Examin							
10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.							
• • • • • • • • • • • • • • • • • • • •	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the E							
Priority under 35 U.S.C. §§ 119 and 120	Examiner. Note the attached Office	Action of format 10-132.					
12) △ Acknowledgment is made of a claim for foreig	an priority under 35 LLS C & 110/s	a)_(d) or (f)					
a) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documer 2. Certified copies of the priority documer 3. Copies of the certified copies of the priority application from the International Burea * See the attached detailed Office action for a lis 13) Acknowledgment is made of a claim for domes since a specific reference was included in the first sentence of the priority document is made of a claim for domes and the priority of the foreign language priority and the priority document is made of a claim for domes reference was included in the first sentence of the priority document is made of a claim for domes reference was included in the first sentence of the priority document is made of a claim for domes reference was included in the first sentence of the priority document is made of a claim for domes reference was included in the first sentence of the priority document is made of a claim for domes reference was included in the first sentence of the priority document is made of a claim for domes reference was included in the first sentence of the priority document is made of a claim for domes reference was included in the first sentence of the priority document is made of a claim for domes reference was included in the first sentence of the priority document is made of a claim for domes reference was included in the first sentence of the priority document is made of a claim for docume	nts have been received. Into have been received in Applicate only documents have been received in Applicate (PCT Rule 17.2(a)). Into of the certified copies not receive the priority under 35 U.S.C. § 119 (irst sentence of the specification of the priority under 35 U.S.C. §§ 120 (irst priority unde	ion No ed in this National Stage ed. e) (to a provisional application) r in an Application Data Sheet. ceived. and/or 121 since a specific					
Attachment(s)	_						
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449) Paper No(s) 	5) Notice of Informal F	r (PTO-413) Paper No(s) Patent Application (PTO-152)					

Art Unit: 2811

DETAILED ACTION

Claim Objections

1. Claims 18-36 are objected to because of the following informalities and/or defects:

Claims 18 and 36 each recite the term of "a conductive layer formed on the source region, the gate conductive layer and the body contact region" but fail to clarify whether this conductive layer comprising a single continuous piece (which is not supported by the original disclosure) or multiple separated pieces.

Appropriate correction is required.

Claim Rejections - 35 USC § 103

- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 28-36, rejected under 35 U.S.C. 103(a) as being unpatentable over Tyson (US 5,317,181) in view of Cherne (US H1435; of record).

Tyson discloses a semiconductor device (see Figs. 1-3) having an SOI structure, comprising: an insulating layer (34; oxide); an insular silicon region (P-; inherently a single crystal layer) including an insular body region (18, P-), a channel (32); a gate oxide layer (34); a gate conductive layer (12); a heavily doped body contact region (22)

Art Unit: 2811

and/or 24), a source region (14; n+); a drain region (16; n+); a conductive layer (26; TiSi, a salicide), wherein the body contact region being in contact with and connected to the source region and the insular body region, and the heavily doped body contact region does not overlap with the gate.

Although Tyson does not expressly disclose that the gate conductive layer can also be covered by a salicide layer from the same conductive layer, one of ordinary skill in the art would be readily recognize that the gate conductive layer, the source region and the body contact region can all be desirably covered by a salicide layer comprising a same metal silicide layer during a same salicide process for reducing the interconnection resistance, as evidenced in Cherne (see the salicide layer (95) covering the gate conductive layer (21), the source region (16) and the body contact region (72, 74, and/or 76) in Figs. 9 and 10, with the source electrode connected to the source region (N+ SOURCE) through the salicide conductive layer (95)).

Therefore, it would have been obvious to one of ordinary skilled in the art at the time the invention was made to incorporate the salicide struture of Cherne into the semiconductor device of Tyson, so that a MOSFET device reduced interconnection resistance would be obtained.

Regarding claim 36, the MOSFET Tyson can also be formed as a P-channel MOSFET (see col. 6, lines 48-49), which would be naturally have a P-type source region and an N-type channel region.

Art Unit: 2811

3. Claims 18-27 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tyson in view of Cherne, as applied to claims 28-36 above, and further in view of Bahraman (US 5,001,528).

The disclosures of Tyson and Cherne are discussed as applied to claims 28-36 above.

Although Tyson and Cherne do not expressly disclose that the geometry of the source structure can be symmetrical to that of the drain structure in the sense that they have a same width and a same length, one of ordinary skill in the art would readily recognize that such a symmetry can be readily and desirably formed for achieving maximum effective channel width with structure simplicity, as evidenced in Bahraman (see the substantially symmetrical source region (2a) and drain region (2b) in Figs. 1-3).

Therefore, it would have been obvious to one of ordinary skilled in the art at the time the invention was made to incorporate the symmetric source/drain structure of Bahraman into the semiconductor device collectively taught by Tyson and Cherne, so that a MOSFET device with maximum effective channel width and structure simplicity would be obtained.

Regarding claim 23, the extended gate electrode portion in Fig. 1 of Tyson can be regarded as the recited gate electrode. And, a drain electrode is also always naturally included in a MOSFET, as shown in Fig. 10 of Cherne).

Art Unit: 2811

Response to Arguments

4. Applicant's arguments with respect to claims 18-36 have been considered but are most in view of the new ground(s) of rejection.

Conclusion

5. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Shouxiang Hu whose telephone number is (703) 306-5729. The examiner can normally be reached on Monday through Thursday, 7:30 AM to 6:00 PM.

Page 6

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Eddie C. Lee can be reached on (703) 308-1690. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9318.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

SH

November 18, 2003

SHOUXIANG HU PRIMARY EXAMINER